



Figure 2. Thermochromism of poly(bis(*p*-*n*-butoxyphenyl)silane) in *p*-*tert*-butylbenzene: (—) 35 °C, (---) 75 °C, (- - -) 150 °C.

2 shows the thermochromic behavior for a solution of 3 in *p*-*tert*-butylbenzene. The spectral changes observed with temperature are completely reversible. The implication from the variable temperature behavior of 3 is that backbone conformational changes are occurring and at high temperatures significantly longer planar zigzag segments of the polymer chain are present. The UV spectra of the poly(bis(*p*-alkoxyphenyl)silanes) at elevated temperatures closely resemble those previously reported for the poly(bis(*p*-alkylphenyl)silanes) at ambient temperatures, although the spectral width of the long wavelength absorption is somewhat greater for the former.

The origin of this unusual substituent effect is interesting to contemplate. It seems unlikely in nonpolar solvents that the steric demands of the *p*-alkoxy substituents are significantly greater than those of the comparable *p*-alkyl groups. Furthermore, space-filling molecular models suggest that both types of *p*-aryl substituents can be nicely accommodated into a planar zigzag backbone conformation by a slight twisting of the aromatic rings so that the plane of the ring is not exactly perpendicular to that of the polymer backbone. However, a trans coplanar backbone leads to an alignment of the *p*-alkoxy substituent dipoles on silicon atoms which are 1,3 to one another. Perhaps, it is this unfavorable dipole alignment rather than steric effects which destabilizes the planar zigzag form and causes it to twist.

If this is the case, substitution at the meta positions on the ring relative to silicon should bring some relief, since the substituent dipoles on the aromatic rings positioned 1,3 to one another could adopt a conformation where they are not in alignment. Consistent with this proposal, the UV spectrum of the meta-disubstituted derivative 4 shows a strong, narrow absorption (ϵ/SiSi 18 300, FWHH = 11 nm) at 403 nm with only a weak, barely detectable shoulder at 325 nm.

Similarly, when the symmetrical, substitution pattern of the bis(*p*-alkoxyphenyl)silane polymers was disturbed by either the formation of the 1:1 copolymer 6 or by the generation of the atactic, unsymmetrically substituted homopolymer 5, changes were observed in the UV spectra. In this regard, the UV spectra of both 5 and 6 exhibited two absorption maxima around 322 and 400 nm, the intensities of which were comparable. These spectra were also thermochromic in the fashion described earlier. In addition, the absorption spectra of 5 and 6 were both solvent dependent. For example, for 5, the ratio of the absorbance at 324 nm to that at 400 nm changed from a value of 1.3 when measured in hexane to ~0.38 in THF solvent. This solvatochromic behavior is also consistent with the suggestion of a delicate conformational equilibrium which is perturbed by the interaction of the polar solvent with the dipolar substituents.

In summary, the poly(bis(alkoxyphenyl)silanes) constitute another class of substituted silane polymers with interesting spectroscopic properties. The unexpected spectral effects caused by the presence of *p*-alkoxy substituents appear to be conformational in origin as suggested by their thermochromism. In addition, certain unsymmetrically substituted materials are solvatochromic due to conformational changes induced by solute-solvent interactions.

Acknowledgment. R. D. Miller gratefully acknowledges partial financial support from the Office of Naval Research.

Registry No. 1 (homopolymer), 116102-67-1; 1 (SRU), 116102-79-5; 2 (homopolymer), 116102-69-3; 2 (SRU), 116102-80-8; 3 (homopolymer), 116102-71-7; 3 (SRU), 116102-81-9; 4 (homopolymer), 116102-73-9; 4 (SRU), 116102-82-0; 5 (homopolymer), 116102-75-1; 5 (SRU), 116102-83-1; 6 (homopolymer), 116102-76-2; 7 (homopolymer), 116102-78-4; 7 (SRU), 116102-84-2.

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Received April 8, 1988;

Revised Manuscript Received July 15, 1988

Preparation of Controlled Molecular Weight, Olefin-Terminated Polymers by Free Radical Methods. Chain Transfer Using Allylic Sulfides

Carbon-centered radicals react with allylic sulfides of general structure 1, to effect $\text{S}_\text{H}2'$ displacement of the thiyl group (Scheme I).¹ The mechanism may be visualized as an initial radical addition to the olefinic center of 1 fol-

acrylate) ($\bar{M}_n = 4900$) prepared with 3 contained signals at δ 5.45 and 6.20, due to the double bond, and a signal centered at δ 4.15, consistent with the incorporation of the ethyl ester moiety.

Since styryl, α,β -unsaturated ester, and α,β -unsaturated nitrile end groups are potentially polymerizable, the low molecular weight polymers prepared by using 3, 5, and 6 are likely to possess the properties of a macromonomer. We are currently investigating both the reactivity of these polymers and the likelihood that appropriately substituted allylic sulfides will be useful for the preparation of low molecular weight mono- and di-end-functional polymers.

Acknowledgment. The technical assistance of Donna McIntosh and Yen K. Chong is gratefully acknowledged. We thank R. I. Willing for obtaining the ^1H NMR spectra.

Registry No. 3, 92822-43-0; 5, 116233-34-2; 6, 116233-35-3; STY, 100-42-5; MMA, 80-62-6.

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- (6) These compounds were prepared by reaction of the appropriate bromo compound with 2-methyl-2-propanethiolate ion. They were characterized by ^1H NMR and mass spectra and their purity was checked by TLC on silica gel.
- (7) The ^1H NMR free induction decay was transformed, rephased, and carefully integrated five times. The standard deviation of the ratios determined in this way was 3%.
- (8) Although the analyzed sulfur content was 0.6%, which is less than that expected (1%), if every polymer chain is initiated with a butylthio group, the precision of the determination is such that accurate quantitation at this low level is not possible. The sulfur content of polystyrene ($\bar{M}_n = 3600$) prepared with 5 and of poly(methyl methacrylate) ($\bar{M}_n = 4900$) prepared with 3 was found to be 0.8% and 0.6%, respectively.

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Received April 1, 1988

CORRECTIONS

Toshio Masuda,* Eiji Isobe, and Toshinobu Higashimura*: Polymerization of 1-(Trimethylsilyl)-1-propyne by Halides of Niobium(V) and Tantalum(V) and Polymer Properties. Vol. 18, Number 5, May 1985, p 841.

The UV-visible spectrum and the values of λ_{max} and ϵ_{max} were incorrect. The λ_{max} and ϵ_{max} should read 234 nm and 3400, respectively; there is no absorption above 290 nm. Similar absorptions are observed in the following analogues: $(\text{MeC}\equiv\text{CSiMe}_2\text{-}n\text{-C}_6\text{H}_{13})_n$ λ_{max} 235 nm, ϵ_{max} 3480; $(\text{MeC}\equiv\text{CSiMe}_2\text{CH}_2\text{SiMe}_3)_n$ λ_{max} 236 nm, ϵ_{max} 3480.